

Title (en)

METHOD FOR GENERATING AND CIRCULATING A FOAM IN AN INSTALLATION AND DEVICE FOR CARRYING OUT SAID METHOD

Title (de)

VERFAHREN ZUR HERSTELLUNG UND UMWÄLZUNG EINES SCHAUMS IN EINER INSTALLATION UND VORRICHTUNG ZUM DURCHFÜHREN DES VERFAHRENS

Title (fr)

PROCEDE DE GENERATION ET DE MISE EN CIRCULATION D'UNE MOUSSE DANS UNE INSTALLATION ET DISPOSITIF POUR LA MISE EN OEUVRE DE CE PROCEDE

Publication

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Application

EP 99900935 A 19990115

Priority

- FR 9900075 W 19990115
- FR 9800436 A 19980116

Abstract (en)

[origin: FR2773725A1] The system of generation and circulation of a foam is designed to function at pressures lower than or equal to atmospheric. The foam can be prepared for cleaning or decontamination purposes. A process for the generation of a foam from liquid and gaseous phases in which the phases are aspirated through a porous packing material. The foam can be circulated to a primary extremity of the installation and thence to a secondary extremity. The depression is created, by means of a vacuum pump, beyond the second extremity. Independent claims are also included for the foam generation unit and the installation for circulation of the generated foam.

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